Supporting Information for Modified Photoanode by In Situ Growth of

Covalent Organic Frameworks on ${\rm BiVO}_4$ for Oxygen Evolution Reaction

Anni Guo,^{‡,a} Xingchun Wu,^{‡,a} Syed Husnain Ali,^a Huawei Shen,^c Ligong Chen,^{*,a,b} Yang Li^{a,b} and Bowei Wang^{*,a,b}

^a School of Chemical Engineering and Technology, Tianjin University, Tianjin 300350, P. R. China

^b Institute of Shaoxing, Tianjin University, Zhejiang 312300, P. R. China

^c Shaoxing Xingxin New Materials Co., Ltd., Shaoxing 312300, Zhejiang, P. R. China

* Corresponding author at: School of Chemical Engineering and Technology, Tianjin University, Tianjin 300350, P. R. China.

E-mail address: bwwang@tju.edu.cn (Bowei Wang, ORCID ID: 0000-0002-9400-0698); lgchen@tju.edu.cn (Ligong Chen, ORCID ID: 0000-0002-3442-5694)

[‡] These authors contributed equally to this work.

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Characterization

The FT-IR spectra were obtained on a Nicolet 22 AVATAR 370 FT-IR spectrometer as a KBr pellet. X-ray powder diffraction analysis was performed on a Rigaku D/max 2500 X-ray diffractometer with Cu Kα radiation. Scanning electron microscopy (SEM) images were collected on a Hitachi Co. S4800 field emission scanning electron microscope. A field emission transmission electron microscope (JEM-2100F) was used to collect high-resolution transmission electron microscopy (HRTEM) images and energy-dispersive X-ray spectroscopy (EDS) was carried out in STEM mode. Diffuse reflectance ultraviolet-visible (DR UV-vis) spectra were recorded on a Shimadzu UV-3600 spectrophotometer. X-ray photoelectron spectroscopy (XPS) was performed on an X-ray ESCALAB 250Xi spectrometer.

Electrochemical and photoelectrochemical measurements

Electrochemical and photoelectrochemical tests were conducted with a typical three-electrode system, in which a platinum plate electrode and a saturated calomel electrode were used as the counter electrode and reference electrode, respectively. Phosphate buffer (0.2 M, pH=7) was used as the electrolyte. A 300 W Xe lamp with an AM 1.5 G filter (Perfect, PLS-SXE300C, China) was the light source and the light intensity reaching the reactor was 100 mW/cm². Electrochemical and photoelectrochemical performance was tested by a Zahner IM6 electrochemical workstation. Electrochemical impedance spectra were recorded at 1.23 V vs. RHE with an amplitude of 10 mV from 0.01 Hz to 100 000 Hz. I–t curves were obtained at 1.23 V vs. RHE.

Figures



Scheme. S1 Monomers and structures diagram of COF-Azo and COF-Ben



Fig. S1 (a) HRTEM image and (b) element mapping of BiVO₄/COF-Azo; (c) HRTEM image and (d)

element mapping of BiVO₄/COF-Ben



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